## **Supporting information**

## Ultrasensitive UV-NIR Broadband Phototransistors Based on AgBiS<sub>2</sub>-organic Hybrid Films

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## **Supporting figugres**



Fig. S1 Typical PL spectra of the pristine C8-BTBT and C8-BTBT:AgBiS<sub>2</sub> hybrid films.



**Fig. S2** (**a**) Typical SEM image of the hybrid films, (**b**) element statistics of the hybrid films on glass substrates and (**c**-**e**) EDX profiles of the SEM samples.



Fig. S3 (a) Transfer curves of ZTO based phototransistors in dark and under white light filtered with 450 nm long-pass filter, (b) typical absorption spectrum of ZTO films, (c) transfer curves of the AgBiS<sub>2</sub>-organic hybrid phototransistors with SiO<sub>2</sub>/Si substrates in dark and under illumination with various light intensity.



**Fig. S4** Output curves of the optimized C8-BTBT:AgBiS<sub>2</sub> hybrid films based phototransistors in dark.



Fig. S5 The capacitance as a function of frequency of  $Ta_2O_5/PAN$  double dielectric layers.



Fig. S6 Typical field-dependent  $I_{DS}$  of the devices based on pure AgBiS<sub>2</sub> QDs, indicating negligible field-effect transistor performance.



**Fig. S7 (a)** Photocurrent and **(b)** responsivity of the hybrid phototransistors illuminated with various wavelength photons as a function of gate voltage, and **(c)** calculated EQE versus wavelengths.



**Fig. S8** (a) Responsivity and (b) specific detectivity as a function of light intensities under illumination with various wavelengths.



**Fig. S9 (a)** Photocurrent and **(b)** responsivity of the blend films based phototransistors under 365 nm LED with different light intensities.



Fig. S10 Noise density of the blend films based phototransistors at  $V_{DS} = -40$  V and  $V_{GS} = -6$  V.



**Fig. S11 (a)** Transfer curves of C8-BTBT phototransistors in dark, and under 365 nm and 395 nm LEDs, respectively, **(b)** responsivity of C8-BTBT phototransistors under 365 nm LED as a function of gate voltage.